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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:
Schneider, et al.
Serial No: 10/701,233
Filed: November 3, 2003
For: "Method for a Patterned Etch Using a Holographic
Mask"

: Date: 9/3/04
: Group Art Unit: 3729
: Examiner: unknown

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O.Box 1450
Alexandria, VA 22313-1450

Sir:

This Information Disclosure Statement is being submitted pursuant to 37 C.F.R. §1.56 and §1.97.

The Examiner is requested to consider and make of record the references cited on the accompanying Form PTO-1449.

This Information Disclosure Statement should not be construed as a representation that a search has been made, nor should it be construed as an admission that the information cited in the statement is, or is considered to be, material to patentability as defined in § 1.56(b).

If any fees are required, please charge them to Deposit Account No. 22-0265. This form is submitted in duplicate.

Respectfully submitted,

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I hereby certify that this correspondence is being deposited in the United States Postal Service as First Class Mail in an envelope addressed to the Honorable Commissioner for Patents, Mail Stop: IDS, P. O. Box 1450 Alexandria, VA 22313-1450 on Sept. 3, 2004.

